Automotive Electronics Council

Component Technical Committee

Agenda

(subject to change)

2015 - Seventeenth Annual Automotive Electronics Reliability Workshop

April 28, 29, & 30

Novi, MI Sheraton Detroit Novi Hotel

Tuesday, April 28, 2015				
		7:30 AM - 8:00 AM	Continental Breakfast (provided)	
		8:00 AM - 8:30 AM	Workshop Introductions	
	1.1	8:30 AM - 9:00 AM	Ron Demcko AVX	Automotive Transient Voltage Control Update: Emergence of Integration MLCCs and New Families of Multi-Layer Varistors
Session 1:	1.2	9:00 AM - 9:30 AM	Victor Andoralov KEMET Electronics AB, Sweden	High Performance Axial Capacitors for Automotive Electronics
Passive Component Technology 8:30 AM - 10:30 AM	1.3	9:30 AM - 10:00 AM	Ron Demcko AVX	Automotive Grade RF Devices Update
	1.4	10:00 AM - 10:30 AM	John Bultitude KEMET Electronics	Miniaturization of High Voltage BME X7R Multi-Layer Ceramic Capacitors for Use in Automotive Applications
10:30 AM - 11:00 AM BREAK: Coffee, drinks, snacks (provided)				
Session 2:	2.1	11:00 AM - 11:30 AM	Rick Chu <i>Vishay Diode</i>	Solderability Test Specification on Exposed Pad (EP) Discrete Products
Discrete Semiconductor Technology	2.2	11:30 AM - 12:00 PM	F. Pintacuda STMicroelectronics	Relative Humidity Effect on High Voltage power MOSFET HAST Performances
11:00 AM - 12:00 PM	2.3	Withdraw	n	
		12:00 PM - 1:30 PM	LUNCH (on own)	
Workshop Session - W.1 1:30 PM - 2:30 PM		AEC-Q102 LED Qualification Review & Discussion Moderator: Ludger Kappius, Hella KGaA		
2:30 PM - 3:00 PM		BREAK: coffee, drinks, snacks (provided)		
Workshop Session - W.2 3:00 PM - 4:00 PM		Q200 Document Revision Status & Discussion Moderator: AEC Q200 Technical Committee		
Workshop Session - W.3 4:00 PM - 5:00 PM		Q101 Document Status & Discussion Moderator: AEC Q101 Technical Committee		
		5:00 PM	SESSION CLOSE	

Wednesday, April 29, 2015				
		7:30 AM - 8:00 AM	Continental Breakfast (provided)	
Session 3: Cu Wire / Interconnect Technology 8:00 AM - 10:00 AM	3.1	8:00 AM - 8:30 AM	Rene Rongen NXP Semiconductors	Cu-Wire Bonding Process Control for Automotive Electronics
	3.2	8:30 AM - 9:00 AM	Alberto Mancaleoni STMicroelectronics	Extended Lifetime Study of Copper and Copper-Palladium Bonding Wires
	3.3	9:00 AM - 9:30 AM	Zhongning Liang NXP Semiconductors	Impact of Particles on Cu Wire Bonding Reliability
	3.4	9:30 AM - 10:00 AM	R. Enrici Vaion STMicroelectronics	Metal Fatigue in Copper Pillar Flip Chip BGA: A Refined Acceleration Model for the Aluminum Pad Cracking Failure Mode
		10:00 AM - 10:30 AM	BREAK: Coffee, drinks, snacks (p	provided)
	4.1	10:30 AM - 11:00 AM	Reynaldo Ramirez Jr. AMS AG, Austria	Influence of Scribe Line Structures and Incomplete Polyimide Coverage to Temperature Cycle Performance of Encapsulated Integrated Circuits
Session 4: Reliability Improvements 10:30 AM - 12:30 PM	4.2	11:00 AM - 11:30 AM	Mykola Blyzniuk <i>Melexis</i>	Post Stress Assessment of Wire-Bond Pull Tests
	4.3	11:30 AM - 12:00 PM	Warren Chen Macronix International Co.	NOR Flash Management Methods for high Reliability Applications
	4.4	12:00 PM - 12:30 PM	Lieyi Sheng ON Semiconductor	The Physical Interpretations and Reliability Challenges of Interfacial Roughness in Poly-Oxide-Poly Capacitors for Voltage-Elevated Automotive Electronics
		12:30 PM - 2:00 PM	LUNCH (on own)	

Wednesday, April 29, 2015 (continued)				
Session 5:	5.1	2:00 PM - 2:30 PM	Thomas Jost AMS	Gaining Knowledge of Integrated Semiconductor Design Margin by Concept of Functional Robustness Validation
Zero Defects & Mission Profile Initiatives	5.2	2:30 PM - 3:00 PM	Wes Smith Galaxy Semiconductor / Micronas	Multi-Variate Part Average Testing Finds Hidden Outliers: A Case Study of Field Returns at Micronas
2:00 PM - 5:40 PM	5.3	3:00 PM - 3:30 PM	Joy Gandhi <i>Qualicent Analytics</i>	Advanced Analytics for Zero Defects: Pre-prototype and Beyond
3:30 PM - 3:50 PM BREAK: Coffee, drinks, snacks (provided)				
	5.4	3:50 PM - 4:20 PM	Anil Gandhi <i>Qualicent Analytics</i>	Prediction and Screening of Field Failures with Advanced Analytics
Session 5: (Continued)	5.5	4:20 PM - 4:50 PM	Dr. Horst Lewitschnig Infineon Technologies	New Methods for Calculating Early Life Failure Probabilities
	5.6	4:50 PM - 5:40 PM	Werner Kanert, Bob Knoell, Rene Rongen Infineon Technologies & NXP Semiconductors	Understanding The Relationship Between Failure Mechanism-Driven Stress Test and Application-Specific (Robustness Validation) Test Qualification Methods
Workshop Session - W.4 5:40 PM - 6:30 PM		Multi-Chip Module (MCM)/Hybrid Qualification Update Moderator: Tom Lawler, Lattice Semiconductor		
		6:30 PM	SESSION CLOSE	

Thursday, April 30, 2015					
		7:30 AM - 8:00 AM	Continental Breakfast (provided)		
Session 6: EOS/ESD Developments 8:00 AM - 9:30 AM	3.1	8:00 AM - 8:30 AM	Alan Righter Analog Devices	The New JS-002 Joint JEDEC/ESDA CDM Standard: Towards A Single CDM Test Platform for AEC Harmonization	
	3.2	8:30 AM - 9:00 AM	Sandy Yen ISSI	Various Methods To Enhance Device Robustness Against EOS/ESD	
	3.3	9:00 AM - 9:30 AM	Alan Righter Analog Devices	Industry Council Update: Understanding Electrical Overstress - EOS	
9:30 AM - 10:00 AM BREAK: Coffee, drinks, snacks (provided)					
Workshop Session - W.5 10:00 AM - 11:00 AM		MEMs Qualification Update Moderator: Earl Fisher, Autoliv Electronics			
Workshop Session - W.6	6	11:00 AM - 12:00 PM	Q100 Rev H Document Overview & New AEC Initiatives Moderator: AEC Q100 Technical Committee		
WRAP-UP		12:00 PM - 12:30 PM	AEC Technical Committee	Closing Statements & Workshop Adjourned	